

Citations for Ion = **He** , Target = **Si**

Pub. Year	Authors, Title, Journal Citation and Comments	Citation Numb
1956	Gobeli, G. W. 'Range-Energy Relation for Low-Energy Alpha Particles in Si, Ge and Insb' <i>Phys. Rev., 103, 275-78 (1956)</i> <i>Comment : R. 0.70-4.45 MeV He -> Si, Ge, InSb, Al, Cu, Ag, Au.</i>	1956-Gobe 0056
1958	Garin, A. Faraggi, H. 'Parcours Des Alpha De 4.5 MeV Dans L'Uranium, L'Or, Le Zirconium Et Le Silicium.' <i>J. Phys. Radium, 19, 76-78 (1958)</i> <i>Comment : R. 4.5 MeV He -> Si, Zr, Au, U. Ranges From He-Particle Emission From Uranium Alloys.</i>	1958-Gari 0773
1965	Sattler, A. R. 'Ionization Produced by Energetic Silicon Atoms Within a Silicon Lattice' <i>Phys. Rev. A, 138, 1815-21 (1965)</i> <i>Comment : S. 21.2 - 3139 keV Si -> Si</i>	1965-Satt 0216
1966	Maccabee, H. D. Raju, M. R. Tobias, C. A. 'Fluctuations of Energy Loss in Semiconductor Detectors' <i>IEEE Trans. Nucl. Sci., NS-13, No. 6, 176-79 (1966)</i> <i>Comment : dS. 730 MeV H, 910 MeV He -> Si</i>	1966-Macc 0730
1968	Maccabee, H. D. Raju, M. R. Tobias, C. H. 'Fluctuations of Energy Loss by Heavy Charged Particles in Thin Absorbers' <i>Phys. Rev., 165, 469-74 (1968)</i> <i>Comment : dS. 45, 730 MeV H, 910 MeV He, 370 MeV Pi- -> Si</i>	1968-Macc 0314
1970	Avdeichikov, V. V. Gridnev, G. F. Lozhkin, O. V. Perfilov, N. A. 'The Limiting Energy Resolution of Thin De/Dx Detectors for 5-9 MeV Alpha Particles' <i>Bull. Acad. Sci. USSR Phys. Ser., 34, No. 1, 190-96 (1970)</i> <i>Comment : dS. 5-8.7 MeV He -> Si</i>	1970-Avde 0711
1971	DellaMea, G. Drigo, A. V. LoRusso, S. Mazzoldi, P. Bentini, G. G. 'Energy Loss of H, D, and 4He Ions Channeled through Thin Single Crystals of Silicon' <i>Phys. Rev. Letters, 27, 1194-96 (1971)</i> <i>Comment : S. 0.9-5.0 MeV H, D, He -> Si Cryst. And Amorph.</i>	1971-Dell 0132
1971	Thompson, D. A. Mackintosh, W. D. 'Stopping Cross Sections for 0.3 - 1.7 MeV Helium Ions in Silicon and Silicion Dioxide.' <i>J. Appl. Phys., 42, 3969-76 (1971)</i> <i>Comment : S. 0.3-L.7 MeV He -> Si, SiO2</i>	1971-Thom 0492

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1972	DellaMea, G. Drigo, A. V. LoRusso, S. Mazzoldi, P. Bentini, G. G. 'Transmission Energy Loss of Light Channeled Particles in Thin Silicon Single Crystals' <i>Rad. Effects, 13, 115-19 (1972)</i> Comment : S,dS. 0.9-5.0 MeV P, D, He -> Si (Cryst.)	1972-Dell2 0480
1972	Eisen, F. H. Clark, G. J. Bottiger, J. Poate, J. M. 'Stopping Power of Energetic Helium Ions Transmitted through Thin Silicon Crystals in Channeling and Random Directions' <i>Rad. Effects, 13, 93-100 (1972)</i> Comment : S,dS. 0.1-18 MeV He -> Si (Cryst.). Chan. And Random.	1972-Eise 0482
1973	Chu, W. K. Ziegler, J. F. Mitchell, I. V. Mackintosh, W. D. 'Energy-Loss Measurements of 4He Ions in Heavy Metals' <i>Appl. Phys. Letters, 22, 437-39 (1973)</i> Comment : S. 2.0 MeV He -> Al, Si, V, Fe, Co, Ni, Cu, In, Ge, Mo, Sb, Te, Gd, Hf, Ta, W, Ir, Pt, Au, Pb	1973-Chu 3 0124
1973	Feng, J. S. -Y. Chu, W. K. Nicolet, M. -A. Mayer, J. W. 'Relative Measurements of Stopping Cross Section Factors by Back-Scattering' <i>Thin Solid Films, 19, 195-204 (1973)</i> Comment : S (1-2 MeV) He -> Au, Ag, Cu, Al, Si. Relative Stopping	1973-Feng 0503
1973	Lin, W. K. Olson, H. G. Powers, D. 'Alpha-Particle Stopping Cross Sections of Silicon and Germanium' <i>J. Appl. Phys., 44, 3631-34 (1973)</i> Comment : S. 0.3-2.0 MeV He -> Si, Ge (Amorph.)	1973-Lin 0497
1973	Sellers, B. Hanser, A. Kelley, J. G. 'Energy Loss and Stopping Power Measurements Between 2 and 10 MeVamu for 3He and 4He in Silicon.' <i>Phys. Rev. B, 8, 98-102 (1973)</i> Comment : S. 6-30 MeV 3He, 8-40 MeV 4He -> Si (Cryst.?)	1973-Sell 0484
1973	Ziegler, J. F. Brodsky, M. H. 'Specific Energy Loss of 4He Ions in Silicon (Amorphous, Polycrystalline, and Single Crystal)' <i>J. Appl. Phys., 44, 188-96 (1973)</i> Comment : S. 0.42-2.75 MeV He -> Si	1973-Zieg 0474
1974	Avdeichikov, V. V. Ganza, E. A. Lozhkin, O. V. 'Energy-Loss Fluctuation of Heavy Charged Particles in Silicon Absorbers' <i>Nucl. Inst. Methods, 118, 247-52 (1974)</i> Comment : dS. 7.7 MeV He, 255 MeV Ar -> Si	1974-Avde 0628

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1974	Baglin, J. E. E. Ziegler, J. F. 'Tests of Bragg's Rule for Energy Loss of 4He Ions in Solid Compounds' <i>J. Appl. Phys., 45, 1413-1415 (1974)</i> <i>Comment : S. He (2 MeV) -> Si, Rh, Hf, Al, W, C, and many compounds</i>	1974-Bagl 1583
1974	Schmid, K. Fischer, G. Muller, H. Ryssel, H. 'Experimental Data About Dechanneling and Channel Stopping Power' <i>Rad. Effects, 23, 145-49 (1974)</i> <i>Comment : S. 1 MeV He -> Si (Cryst.)</i>	1974-Schm 0519
1975	Bulgakov, Yu. V. Nikolaev, V. S. Shulga, V. I. 'Impact-Parameter Dependence of Inelastic Energy Losses for He and N Ions Channeled in Si' <i>Phys. Stat. Sol. A, 31, 341-50 (1975)</i> <i>Comment : S, dS. 1.3, 6.6 MeV He, 4.4 MeV N -> Si (Cryst.)</i>	1975-Bulg 0799
1975	Schuch, R. 'Blocking-Effekte Bei Transmission von Alpha-Teilchen Durch Germanium - und Siliziumkristalle' <i>Z. Physik A, 272, 61-66 (1975)</i> <i>Comment : S. 8.8 MeV He -> Si, Ge (Cryst.)</i>	1975-Schu 0516
1976	Avdeichikov, V. V. Ganza, E. A. Lozhkin, O. V. 'Energy Resolution of Thin Semiconductor Delta-E Detectors for Alpha Particles and Heavy Ions' <i>Nucl. Inst. Methods, 131, 61-68 (1976)</i> <i>Comment : dS. (1-200 MeV) He, C, N, O, Ne, Ar -> Si</i>	1976-Avde 0882
1976	Grahmann, G. Kalbitzer, S. 'Nuclear and Electronic Stopping Powers of Low Energy Ions with Z <= 10 in Silicon' <i>Nucl. Inst. Methods, 132, 119-23 (1976)</i> <i>Comment : S. 2-60 keV H, He, B, C, N, Ne -> Si</i>	1976-Grah 0871
1976	Hoffman, I. Jager, E. Muller-Jahreis, U. 'Z1-Dependence of Electronic Energy Straggling of Light Ions' <i>Rad. Effects, 31, 57 (1976)</i> <i>Comment : dS. 2 <= Z1 <= 10 (10-100 Kev) -> C, Si</i>	1976-Hoff 1259
1976	Matsumura, H. Furukawa, S. 'Simple Formulation for Energy Straggling of Helium in Silicon' <i>Rad. Effects, 27, 245-46 (1976)</i> <i>Comment : dS. 1-2 MeV He -> Si</i>	1976-Mats 0890
1976	Wilken, B. Fritz, T. A. 'Energy Distribution Functions of Low Energy Ions in Silicon Absorbers Measured for Large Relative Energy Losses' <i>Nucl. Inst. Methods, 138, 331-343 (1976)</i> <i>Comment : dS. 300 keV-1.5 MeV H, 3He -> Si</i>	1976-Wilk 1051

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1977	Holland, O. W. Appleton, B. R. 'Well-Channelled Ions with Greater-Than-Random Energy Loss Rates' <i>IEEE Proc. of 4th Intl. Conf. on Small Accelerators, Denton, Tex. (1977)</i> <i>Comment : S. 1.0 MeV He -> Si <111></i>	1977-Holl 1257
1977	Jarvis, O. N. Sherwood, A. C. Whitehead, C. Lucas, M. W. 'Stopping Power for Fast Channeled Alpha Particles in Silicon' <i>Phys. Rev. B, 16, 3880-3886 (1977)</i> <i>Comment : S. 160 MeV He -> Si ([110], [111], And Random)</i>	1977-Jarv 1038
1977	Thompson, D. A. Robinson, J. E. Walker, R. S. 'Inelastic Stopping of Medium Energy Light Ions in Silicon' <i>Rad. Effects, 32, 169-175 (1977)</i> <i>Comment : dS,R,dR. 10-80 keV H, He, Li, B, C, N, O, Ne -> Si</i>	1977-Thom 1076
1978	Bottiger, J. Jensen, P. S. Littmark, U. 'Depth Profiles of 3He Ions Implanted into Solids at Energies Between 20 and 60 keV' <i>J. Appl. Phys., 49, 965-970 (1978)</i> <i>Comment : R, dR. 20-60 keV 3He -> C, Al, Si, V, Ni, Zr</i>	1978-Bott2 1091
1978	Jarvis, O. N. Sherwood, A. C. Whitehead, C. Lucas, M. W. 'Channeling of Fast Protons, Deuterons and Alpha Particles' <i>Preprint (1978)</i> <i>Comment : S, R, dR. 160 keV He, 81.5 keV D, 158.5 keV H -> Si</i>	1978-Jarv 1148
1978	Oetzmann, H. Kalbitzer, S. '⁴He Stopping Power Measurements by using Ion Implantation and Backscattering Techniques' <i>Intl. Conf. Ion Beam Modification of Materials, Budapest -d (1978)</i> <i>Comment : S. 0.15-1 MeV He -> C, Ge, Si</i>	1978-Oetz 1134
1978	Rosendahl, E. W. Monkediek, J. 'Measurement of the Energy Loss of Non-Channelled Alpha-Particles in Transmission and Interpretation with the Aid of an Averaged Continuum Potential' <i>Z. Physik A, 285, 33-36 (1978)</i> <i>Comment : S. 8.78 MeV He -> Si</i>	1978-Rose 1125
1979	Jarvis, O. N. Sherwood, A. C. Whitehead, C. Lucas, M. W. 'Channeling of Fast Protons, Deuterons, and Alpha Particles' <i>Phys. Rev. B, 19, 5559-5577 (1979)</i> <i>Comment : S, R, dR. 160 keV He, 81.5 keV D, 158.5 keV H -> Si</i>	1979-Jarv 1199
1979	Santry, D. C. Werner, R. D. 'Thickness Measurements of Thin Foils using Alpha Particles from ¹⁴⁸Gd and ²⁴¹Am' <i>Nucl. Inst. Methods, 159, 523-527 (1979)</i> <i>Comment : S, dS. 3.138 MeV - 5.486 MeV He -> Be, C, Al, Si, Ni, Ag, Au</i>	1979-Sant3 1350

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1980	Heibei, J. Voges, E. 'Refractive Index of Ion-Implanted Fused Silica' <i>Phys. Stat. Sol. B, 57, 609-618 (1980)</i> <i>Comment : R, dR. 100 keV He, Ar -> Si</i>	1980-Heib 1345
1980	Josquin, W. J. M. J. 'The Oxidation Characteristics of Nitrogen-Implanted Silicon' <i>Rad. Effects, 47, 221-224, (1980)</i> <i>Comment : R, dR. 250-800 keV H, H2, He, B, P -> Si</i>	1980-Josq 1331
1980	Oetzmann, H. Kalbitzer, S. 'He4-Stopping Power Measurements by using Ion Implantation and Backscattering Techniques' <i>Rad. Effects, 47, 73-80 (1980)</i> <i>Comment : S, dS. 0-1E5 keV He -> C, Si, Ge</i>	1980-Oetz 1324
1980	Santry, D. C. Werner, R. D. 'Stopping Power Values of Be, C, Al and Si for 4He Ions' <i>Nucl. Inst. Methods, 178, 523-530 (1980)</i> <i>Comment : S. He (0.2-2.0 MeV) -> Be, C, Al, Si</i>	1980-Sant2 1407
1980	Sofield, C. J. Cowern, N. E. B. Freeman, J. M. 'Charge-Exchange Effects in Energy-Loss Straggling' <i>Nucl. Inst. Methods, 170, 221-225 (1980)</i> <i>Comment : R, dR. 0-50 MeV Atomic Numbers 1-16 -> Al</i>	1980-Sofi 1378
1981	Pearce, J. D. Hart, R. R. 'Stopping Power Measurements in the 20-150 keV Region using Thick Target Backscattering: H and He on C, Si and Au' <i>J. Appl. Phys., 52, 5056 (1981)</i> <i>Comment : S. H, He (20-150 keV) -> C, Si, Au</i>	1981-Pear 1736
1981	Santry, D. C. Werner, R. D. 'Stopping Power Values of C, Al, Si, Ni, Ag and Au for 3He Ions' <i>Nucl. Inst. Methods, 185, 517-521 (1981)</i> <i>Comment : S. He3 (200-2000 keV) -> C, Al, Si, Ni, Ag, Au</i>	1981-Sant2 1449
1984	Santry, D. C. Werner, R. D. 'Stopping Powers of C, Al, Si, Ti, Ni, Ag, Au and Mylar using Radioactive Alpha Sources' <i>Nucl. Inst. Methods, B1, 13 (1984)</i> <i>Comment : S. He (2-7 MeV) -> C, Al, Si, Ti, Ni, Ag, Au, Mylar</i>	1984-Sant 1757
1986	Gnaser, H. Bay, H. L. Hofer, W. 'Depth Distributions of Low Energy He Implanted in Solids' <i>Nucl. Inst. Methods, B15, 49-53 (1986)</i> <i>Comment : R, dR. He (0.25-80 keV) -> Si</i>	1986-Gnas 1523

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1987	Fink, D. Biersack, J. P. Stadele, M. Cheng, V. K. 'Range Profiles of Helium in Solids' <i>Rad. Effects, 104, 1-42 (1987)</i> <i>Comment : R. He-3 (50-1500 keV) -> Be, C, Mg, Al, Si, Ti, V, Mn, Fe, Ca, Ni, Cu, Zn, Ge, Zr, Nb, Mo, Ag, Cd, In, Sn, Sb, Tb, Dy, Er, Ta, W, Ir, Pt, Au, Pb, Bi, SiC, MnO2</i>	1987-Fink 1645
1988	Yamaguchi, S. Takahiro, K. Nakajima, H. Fujino, Y. Sagara, S. 'Energy Loss of He Ions in H-Implanted Materials' <i>Nucl. Inst. Methods, B33, 163-167 (1988)</i> <i>Comment : S. He (1.5 MeV) -> Be, Si, Al (doped with H)</i>	1988-Yama 1962
1993	Narumi, K. Fujii, Y. Kishine, K. Fujiwara, S. Kimura, K. 'Energy Losses of 12-32 keV H, He and N Ions at Glancing Angle Scattering from Clean Surfaces of Silicon Crystals' <i>J. Phys. Soc. Jap., 62, 1603-1611 (1993)</i> <i>Comment : S. H, He, N (12-32 keV) -> Si Surface scattering effects</i>	1993-Naru 2054
1993	Nieman, D. Oberschachtsiek, P. Kalbitzer, S. Zeindl, H. P. 'Energy Loss and Straggling of MeV He-4 Ions in a Si/Sb Multilayer Target' <i>Nucl. Inst. Methods, B80/81, 37-40 (1993)</i> <i>Comment : S, dS. He (0.1-4.0 MeV) -> Si/Sb Layers</i>	1993-Niem 1868
1995	Dos Santos, J. H. R. Grande, P. L. Boudinov, H. Behar, M. Stoll, R. 'Electronic Stopping Power of <100> Axial Channelled He Ions in Si Crystals' <i>Nucl. Inst. Methods, B106, 51-54 (1995)</i> <i>Comment : S. He (0.2-4.5 MeV) -> Si</i>	1995-Dos 1832
1996	Gelfort, S. Kerkow, H. Stolle, R. Petukhov, V. P. Romanowski, E. A. 'Angular Dependence of the Electronic Energy Loss for Low Energy Heavy Ions under Channeling Conditions' <i>Nucl. Inst. Methods, B115, 315-318 (1996)</i> <i>Comment : S. Channeling of ions He to Kr in Si <110></i>	1996-Gelf 1814
1996	Misdaq, M. A. Elassali, R. 'Average Stopping Powers for Channeled Ions using Calculational and Experimental Methods' <i>Nucl. Inst. Methods, 119, 325-330 (1996)</i> <i>Comment : S. Light ions -> Si, GaAs (channeled)</i>	1996-Misd 0964
1996	Niemann, D. Kinac, G. Kalbitzer, S. 'Stopping Power of H, He and N in Si in the Energy Range of 0.02-1.0 MeV/amu' <i>Nucl. Inst. Methods, 118, 11-18 (1996)</i> <i>Comment : S. H, He, N (.02-1.0 MeV/amu) -> Si</i>	1996-Niem 1101

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2000	Hoshino, Y. Okazawa, T. Nishii, T. Nishimura, T. Kido, Y. 'Correction of Ziegler's Stopping Powers of Al, Si and their Oxides for MeV He Ions' <i>Nucl. Inst. Methods, B171, 409-413 (2000)</i> <i>Comment : S. He (1.1 - 2.6 MeV) -> Al, Si</i>	2000-Hosh 2344